

### LISTING OF THE CLAIMS

The following listing of the claims replaces all prior versions and listings of claims for this application. Within this listing of the claims, claims 1 and 21 to 26 are amended and claim 20 is canceled.

1. **(Currently amended)** A process for patterning a substrate, comprising:

(a) coating the substrate with a film of a photoresist composition comprised of (i) a polymer that is rendered soluble in aqueous base at a temperature of less than about 100°C by acid-catalyzed deprotection of pendent acetal- or ketal-protected carboxylic acid groups, and (ii) a photoacid generator;

(b) patternwise exposing the film to an imaging radiation source so as to form a latent, patterned image in the film;

(c) baking the exposed film at a post-exposure bake temperature below about 100°C; and

(d) developing the latent image with a developer to form a patterned substrate,

wherein the polymer is prepared by polymerization of a monomer mixture, the mixture comprising (a) at least one first olefinic monomer containing an acetal or ketal linkage, the acid-catalyzed cleavage of which renders the polymer soluble in aqueous base, and (b) at least one second olefinic monomer selected from (i) an olefinic monomer containing a pendant fluorinated hydroxyalkyl group R<sup>H</sup>, (ii) an olefinic monomer containing a pendant fluorinated alkylsulfonamide group R<sup>S</sup>, and (iii) combinations thereof.

2. **(Original)** The process of claim 1, wherein the radiation is electron-beam, x-ray, ultraviolet, or extreme ultraviolet radiation.

3. **(Original)** The process of claim 2, wherein the radiation is ultraviolet radiation.

4. **(Original)** The process of claim 3, wherein the ultraviolet radiation has a wavelength of 193 nm, 157 nm, or 13.4 nm.

5. **(Original)** The process of claim 4, wherein the ultraviolet radiation has a wavelength of 193 nm.

6. **(Original)** The process of claim 4, wherein the ultraviolet radiation has a wavelength of 157 nm.

7. **(Original)** The process of claim 1, further comprising etching the patterned substrate.
8. **(Original)** The process of claim 7, wherein the etching comprises ion etching.
9. **(Original)** The process of claim 1, wherein the film is insoluble in aqueous base, and wherein the imaging radiation renders the film soluble in the aqueous base where exposed to the imaging radiation source.
10. **(Original)** The process of claim 9, further comprising removing the soluble portions of the film.
11. **(Original)** The process of claim 1, wherein the substrate is ceramic, metallic, semiconductive, or a combination thereof.
12. **(Original)** The process of claim 1, wherein the substrate comprises a silicon wafer, a photolithographic mask blank, or a printed circuit board.
13. **(Original)** The process of claim 1, wherein the substrate comprises silicon dioxide, silicon nitride, silicon oxynitride, or a combination thereof.
14. **(Original)** The process of claim 1, further comprising, before exposure of the film in (b), performing a prebake of the film at a temperature and for a time sufficient to remove residual solvent.
15. **(Original)** The process of claim 14, wherein the prebake temperature is below about 130°C.
16. **(Original)** The process of claim 1, wherein the post-exposure bake temperature is between about 25°C and about 100°C.
17. **(Original)** The process of claim 16, wherein the post-exposure bake temperature is between about 25°C and about 80°C.

18. **(Original)** The process of claim 17, wherein the post-exposure bake temperature is between about 25°C and about 50°C.

19. **(Original)** The patterned substrate prepared by the process of claim 1.

20. **(Canceled)**

21. **(Currently amended)** The process of claim [[20]] 1, wherein the acetal or ketal linkage is contained within an acid-cleavable group  $R^{CL}$  in the first olefinic monomer, the acid-cleavable group having the structure



in which:

m, n, and q are independently zero or 1;

$L^1$  is selected from  $C_1$ - $C_{12}$  alkylene, substituted  $C_1$ - $C_{12}$  alkylene,  $C_1$ - $C_{12}$  heteroalkylene, substituted  $C_1$ - $C_{12}$  heteroalkylene, and further wherein when  $L^1$  is optionally substituted and/or heteroatom-containing  $C_1$ - $C_{12}$  alkylene,  $L^1$  may be linear, branched, or cyclic;

X is selected from  $C_3$ - $C_{30}$  alicyclic and substituted  $C_3$ - $C_{30}$  alicyclic;

$L^2$  is selected from  $C_1$ - $C_{12}$  alkylene, substituted  $C_1$ - $C_{12}$  alkylene,  $C_1$ - $C_{12}$  heteroalkylene, substituted  $C_1$ - $C_{12}$  heteroalkylene, and further wherein when  $L^2$  is optionally substituted and/or heteroatom-containing  $C_3$ - $C_{12}$  alkylene,  $L^2$  may be linear, branched, or cyclic; and

$R^1$  is selected from acetal-containing and ketal-containing substituents.

22. **(Currently amended)** The process of claim [[20]] 1, wherein  $R^H$  has the structure  $-L^3-CR^{11}R^{12}-OH$ , in which:

$L^3$  is selected from  $C_1$ - $C_{12}$  alkylene, substituted  $C_1$ - $C_{12}$  alkylene,  $C_1$ - $C_{12}$  heteroalkylene, substituted  $C_1$ - $C_{12}$  heteroalkylene,  $C_3$ - $C_{15}$  alicyclic,  $C_3$ - $C_{15}$  fluoroalicyclic, and combinations thereof;

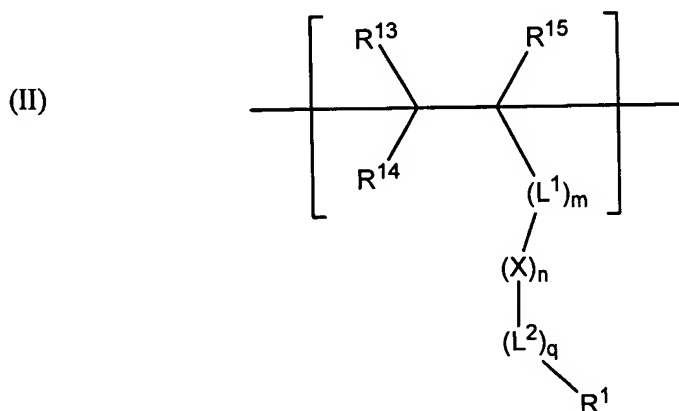
$R^{11}$  is selected from hydrogen,  $C_1$ - $C_{24}$  alkyl, and substituted  $C_1$ - $C_{24}$  alkyl; and

$R^{12}$  is  $C_1$ - $C_{24}$  alkyl or fluorinated  $C_1$ - $C_{24}$  alkyl, with the proviso that at least one of  $R^{11}$  and  $R^{12}$  is fluorinated; and further wherein  $R^{11}$  and  $R^{12}$  can be taken together to form a ring.

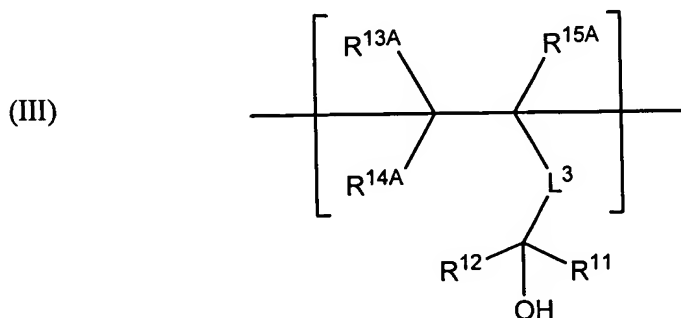
23. **(Currently amended)** The process of claim [[20]] 1, wherein  $R^S$  has the structure  $-L^3-SO_2-NHR^{16}$ , in which:

$L^3$  is selected from  $C_1$ - $C_{12}$  alkylene, substituted  $C_1$ - $C_{12}$  alkylene,  $C_1$ - $C_{12}$  heteroalkylene, substituted  $C_1$ - $C_{12}$  heteroalkylene,  $C_3$ - $C_{15}$  alicyclic,  $C_3$ - $C_{15}$  fluoroalicyclic, combinations thereof; and  $R^{16}$  is selected from  $C_1$ - $C_{24}$  alkyl and substituted  $C_1$ - $C_{24}$  alkyl,  $C_1$ - $C_{24}$  fluoroalkyl and substituted  $C_1$ - $C_{24}$  fluoroalkyl.

24. **(Currently amended)** The process of claim [[20]] 1, wherein the polymer comprises a first olefinic monomer unit having the structure of formula (II)



and a second olefinic monomer unit having the structure of formula (III)



wherein:

$m$ ,  $n$ , and  $q$  are independently zero or 1;

$L^1$  is selected from  $C_1$ - $C_{12}$  alkylene, substituted  $C_1$ - $C_{12}$  alkylene,  $C_1$ - $C_{12}$  heteroalkylene, substituted  $C_1$ - $C_{12}$  heteroalkylene, and further wherein when  $L^1$  is optionally substituted and/or heteroatom-containing  $C_1$ - $C_{12}$  alkylene,  $L^1$  may be linear, branched, or cyclic;

$X$  is selected from  $C_3$ - $C_{30}$  alicyclic and substituted  $C_3$ - $C_{30}$  alicyclic;

$L^2$  is selected from  $C_1$ - $C_{12}$  alkylene, substituted  $C_1$ - $C_{12}$  alkylene,  $C_1$ - $C_{12}$  heteroalkylene, substituted  $C_1$ - $C_{12}$  heteroalkylene, and further wherein when  $L^2$  is optionally substituted and/or heteroatom-containing  $C_3$ - $C_{12}$  alkylene,  $L^2$  may be linear, branched, or cyclic; and

$R^1$  is selected from acetal-containing and ketal-containing substituents;

$L^3$  is selected from  $C_1$ - $C_{12}$  alkylene, substituted  $C_1$ - $C_{12}$  alkylene,  $C_1$ - $C_{12}$  heteroalkylene, substituted  $C_1$ - $C_{12}$  heteroalkylene,  $C_3$ - $C_{15}$  alicyclic,  $C_3$ - $C_{15}$  fluoroalicyclic and combinations thereof;

$R^{11}$  is selected from hydrogen,  $C_1$ - $C_{24}$  alkyl, and substituted  $C_1$ - $C_{24}$  alkyl;

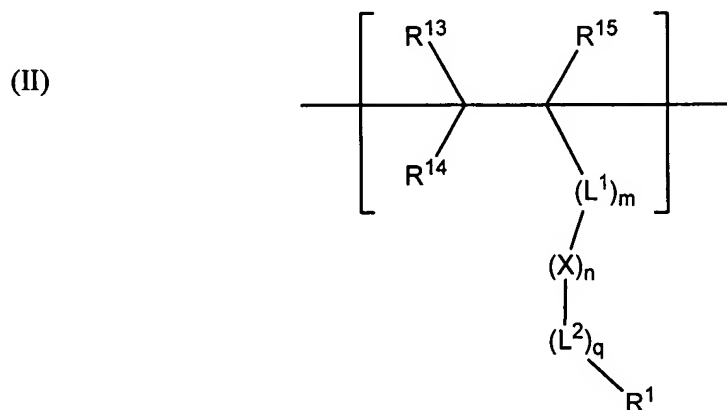
$R^{12}$  is  $C_1$ - $C_{24}$  alkyl or fluorinated  $C_1$ - $C_{24}$  alkyl, with the proviso that at least one of  $R^{11}$  and  $R^{12}$  is fluorinated; and further wherein  $R^{11}$  and  $R^{12}$  can be taken together to form a ring;

$R^{13}$  and  $R^{13A}$  are independently selected from hydrogen, fluorine,  $C_1$ - $C_{24}$  alkyl, substituted  $C_1$ - $C_{24}$  alkyl,  $C_1$ - $C_{24}$  alkoxy, and substituted  $C_1$ - $C_{24}$  alkoxy;

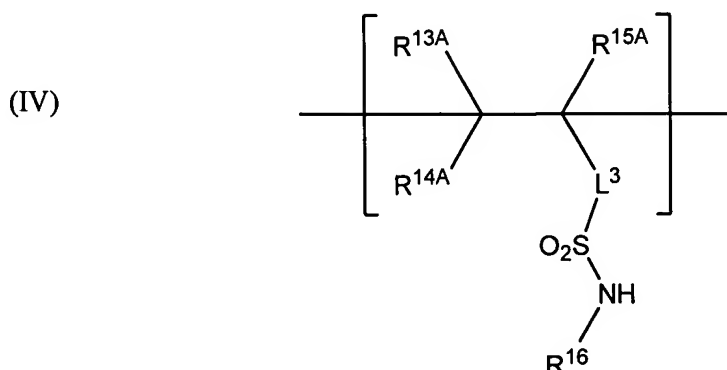
$R^{14}$  and  $R^{14A}$  are independently selected from hydrogen, fluorine,  $C_1$ - $C_{24}$  alkyl and substituted  $C_1$ - $C_{24}$  alkyl; and

$R^{15}$  and  $R^{15A}$  are independently selected from hydrogen, fluorine,  $C_1$ - $C_{24}$  alkyl, and substituted  $C_1$ - $C_{24}$  alkyl, and further wherein any two of  $R^{13}$ ,  $R^{14}$ , and  $R^{15}$  may be taken together to form a ring and any two of  $R^{13A}$ ,  $R^{14A}$ , and  $R^{15A}$  may be taken together to form a ring.

25. (Currently amended) The process of claim [[20]] 1, wherein the polymer comprises a first olefinic monomer unit having the structure of formula (II)



and a second olefinic monomer unit having the structure of formula (IV)



wherein:

m, n, and q are independently zero or 1;

$\text{L}^1$  is selected from  $\text{C}_1\text{-C}_{12}$  alkylene, substituted  $\text{C}_1\text{-C}_{12}$  alkylene,  $\text{C}_1\text{-C}_{12}$  heteroalkylene, substituted  $\text{C}_1\text{-C}_{12}$  heteroalkylene, and further wherein when  $\text{L}^1$  is optionally substituted and/or heteroatom-containing  $\text{C}_1\text{-C}_{12}$  alkylene,  $\text{L}^1$  may be linear, branched, or cyclic;

X is selected from  $\text{C}_3\text{-C}_{30}$  alicyclic and substituted  $\text{C}_3\text{-C}_{30}$  alicyclic;

$\text{L}^2$  is selected from  $\text{C}_1\text{-C}_{12}$  alkylene, substituted  $\text{C}_1\text{-C}_{12}$  alkylene,  $\text{C}_1\text{-C}_{12}$  heteroalkylene, substituted  $\text{C}_1\text{-C}_{12}$  heteroalkylene, and further wherein when  $\text{L}^2$  is optionally substituted and/or heteroatom-containing  $\text{C}_3\text{-C}_{12}$  alkylene,  $\text{L}^2$  may be linear, branched, or cyclic; and

$\text{R}^1$  is selected from acetal-containing and ketal-containing substituents;

$\text{L}^3$  is selected from  $\text{C}_1\text{-C}_{12}$  alkylene, substituted  $\text{C}_1\text{-C}_{12}$  alkylene,  $\text{C}_1\text{-C}_{12}$  heteroalkylene, substituted  $\text{C}_1\text{-C}_{12}$  heteroalkylene,  $\text{C}_3\text{-C}_{15}$  alicyclic,  $\text{C}_3\text{-C}_{15}$  fluoroalicyclic,  $\text{C}_5\text{-C}_{14}$  arylene, substituted  $\text{C}_5\text{-C}_{14}$ ,  $\text{C}_5\text{-C}_{14}$  heteroarylene, substituted  $\text{C}_5\text{-C}_{14}$  heteroarylene, and combinations thereof;

$\text{R}^{13}$  and  $\text{R}^{13\text{A}}$  are independently selected from hydrogen, fluorine,  $\text{C}_1\text{-C}_{24}$  alkyl, substituted  $\text{C}_1\text{-C}_{24}$  alkyl,  $\text{C}_1\text{-C}_{24}$  alkoxy, and substituted  $\text{C}_1\text{-C}_{24}$  alkoxy;

$\text{R}^{14}$  and  $\text{R}^{14\text{A}}$  are independently selected from hydrogen, fluorine,  $\text{C}_1\text{-C}_{24}$  alkyl and substituted  $\text{C}_1\text{-C}_{24}$  alkyl;

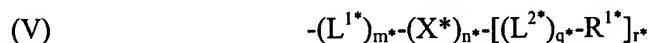
$\text{R}^{15}$  and  $\text{R}^{15\text{A}}$  are independently selected from hydrogen, fluorine,  $\text{C}_1\text{-C}_{24}$  alkyl, and substituted  $\text{C}_1\text{-C}_{24}$  alkyl, and further wherein any two of  $\text{R}^{13}$ ,  $\text{R}^{14}$ , and  $\text{R}^{15}$  may be independently taken together to form a ring and any two of  $\text{R}^{13\text{A}}$ ,  $\text{R}^{14\text{A}}$ , and  $\text{R}^{15\text{A}}$  may be taken together to form a ring; and

$\text{R}^{16}$  is selected from  $\text{C}_1\text{-C}_{24}$  alkyl and substituted  $\text{C}_1\text{-C}_{24}$  alkyl,  $\text{C}_1\text{-C}_{24}$  fluoroalkyl and substituted  $\text{C}_1\text{-C}_{24}$  fluoroalkyl.

26. **(Currently amended)** The process of claim [[20]] 1, wherein the monomer mixture further comprises at least one additional olefinic monomer.

27. **(Original)** The process of claim 26, wherein the at least one additional olefinic monomer is selected from (i) a monomer containing an acid-cleavable substituent  $R^{CL*}$ ; (ii) a monomer containing an acid-inert, polar substituent,  $R^P$ ; (iii) a monomer containing an acid-inert, nonpolar substituent,  $R^{NP}$ ; and (iv) combinations thereof.

28. **(Original)** The process of claim 27, wherein  $R^{CL*}$  has the structure



in which:

$m^*$ ,  $n^*$ , and  $q^*$  are independently zero or 1;

$r^*$  is an integer of at least 1;

$L^{1*}$  is selected from  $C_1$ - $C_{12}$  alkylene, substituted  $C_1$ - $C_{12}$  alkylene,  $C_1$ - $C_{12}$  heteroalkylene, substituted  $C_1$ - $C_{12}$  heteroalkylene, and further wherein when  $L^{1*}$  is optionally substituted and/or heteroatom-containing  $C_1$ - $C_{12}$  alkylene,  $L^{1*}$  may be linear, branched, or cyclic;

$X^*$  is selected from  $C_3$ - $C_{30}$  alicyclic and substituted  $C_3$ - $C_{30}$  alicyclic;

$L^{2*}$  is selected from  $C_1$ - $C_{12}$  alkylene, substituted  $C_1$ - $C_{12}$  alkylene,  $C_1$ - $C_{12}$  heteroalkylene, substituted  $C_1$ - $C_{12}$  heteroalkylene, and further wherein when  $L^{2*}$  is optionally substituted and/or heteroatom-containing  $C_3$ - $C_{12}$  alkylene,  $L^{2*}$  may be linear, branched, or cyclic; and

$R^{1*}$  is selected from acid-cleavable ester, oligomeric ester, ether, carbonate, and orthoester substituents.

29. **(Original)** The process of claim 27, wherein  $R^P$  has the structure



in which:

$m1$ ,  $n1$ , and  $q1$  are independently zero or 1;

$L^3$  is selected from  $C_1$ - $C_{12}$  alkylene, substituted  $C_1$ - $C_{12}$  alkylene,  $C_1$ - $C_{12}$  heteroalkylene, substituted  $C_1$ - $C_{12}$  heteroalkylene, and further wherein when  $L^3$  is optionally substituted and/or heteroatom-containing  $C_1$ - $C_{12}$  alkylene,  $L^1$  may be linear, branched, or cyclic;

$Y$  is selected from  $C_3$ - $C_{30}$  alicyclic and substituted  $C_3$ - $C_{30}$  alicyclic;

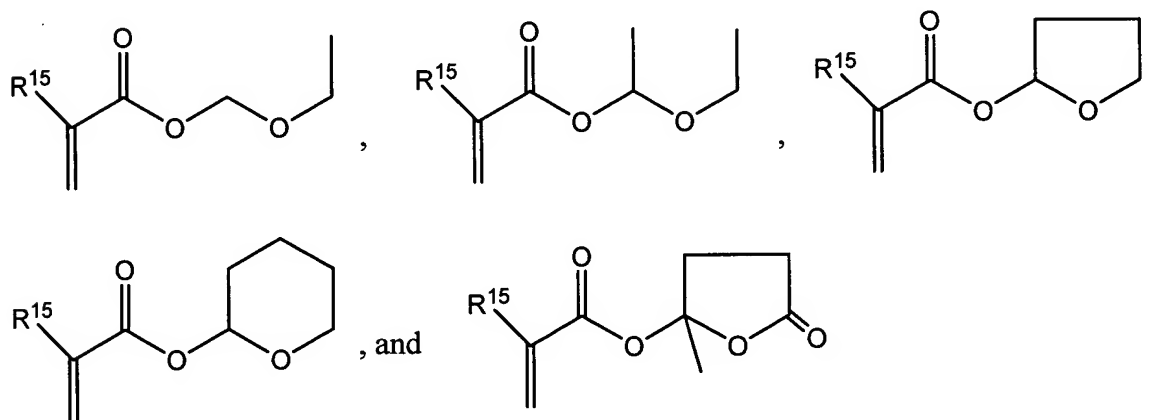
$L^4$  is selected from  $C_1$ - $C_{12}$  alkylene, substituted  $C_1$ - $C_{12}$  alkylene,  $C_1$ - $C_{12}$  heteroalkylene, substituted  $C_1$ - $C_{12}$  heteroalkylene, and further wherein when  $L^4$  is optionally substituted and/or heteroatom-containing  $C_3$ - $C_{12}$  alkylene,  $L^4$  may be linear, branched, or cyclic; and

$R^{18}$  is an acid-inert polar organic group containing a heteroatom with a Pauling electronegativity greater than about 3.00.

30. **(Original)** The process of claim 27, wherein  $R^P$  is selected from lactone, anhydride, sulfonamide, fluoroalkanol, alkanol, alicyclic alkanol, esters, ethers, and a combination thereof.

31. **(Original)** The process of claim 27, wherein  $R^{NP}$  is  $C_1$ - $C_{18}$  hydrocarbyl or fluorinated  $C_1$ - $C_{18}$  hydrocarbyl.

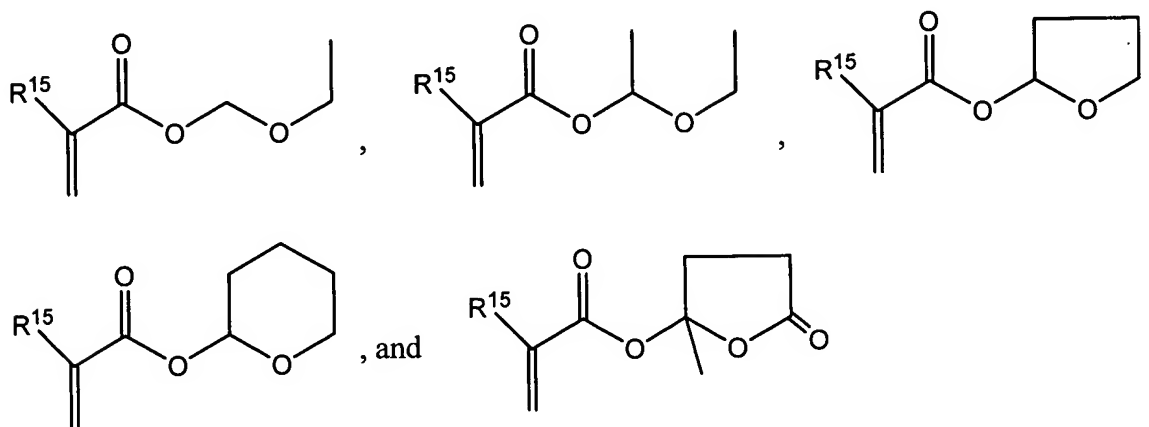
32. **(Original)** The process of claim 24, wherein the first olefinic monomer unit is derived from a monomer having a structure selected from the formulae



33. **(Original)** The process of claim 32, wherein  $R^{15}$  is selected from hydrogen, fluorine,  $C_1$ - $C_{24}$  alkyl, and fluorinated  $C_1$ - $C_{24}$  alkyl.



34. **(Original)** The process of claim 25, wherein the first olefinic monomer unit is derived from a monomer having a structure selected from the formulae



35. **(Original)** The process of claim 34, wherein R<sup>15</sup> is selected from hydrogen, fluorine, C<sub>1</sub>-C<sub>24</sub> alkyl, and fluorinated C<sub>1</sub>-C<sub>24</sub> alkyl.